

ATTY DOCKET NO.

03500.017136.

APPLICATION NO.

10/656,242

APPLICANT

NOBUHIRO YASAI, ET AL.

FILING DATE

September 8, 2003

GROUP

1773

U.S. PATENT DOCUMENTS

| *EXAMINER INITIAL | DOCUMENT NUMBER | DATE | NAME | CLASS | SUBCLASS | FILING DATE IF APPROPRIATE |
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EXAMINER

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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

| FORM PTO 1449 (modified) | | ATTY DOCKET NO. | | APPLICATION NO. | |
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| U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE | | 03500.017136. | | 10/656,242 | |
| LIST OF REFERENCES CITED BY APPLICANT (Use several sheets if necessary) | | APPLICANT | | NOBUHIRO YASAI, ET AL. | |
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